Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	29	(FULLER-S-.in. FULLER-SCOTT-.in. FULLER-SCOTT-EDWARD-.in. MONTGOMERY-MELVIN-.in. MONTGOMERY-MELVIN-W-.in. MONTGOMERY-MELVIN-WARREN-.in. MONTGOMERY-MERLIN-W-.in. MONTGOMERY-M-W-.in. ALBELO-JEFFREY-A-.in. ALBELO-J-A-.in. albelo-.in. BUXBAUM-.in. BUXBAUM-A-.in. buxBAUM-ALEX-.in.) and ((mask photomask photo-mask reticle) near2 (substrate blank))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:29
L3	386	FULLER-SCOTT-.in. FULLER-SCOTT-EDWARD-.in. MONTGOMERY-MELVIN-.in. MONTGOMERY-MELVIN-W-.in. MONTGOMERY-MELVIN-WARREN-.in. MONTGOMERY-M-W-.in. ALBELO-JEFFREY-A-.in. ALBELO-J-A-.in. albelo-.in. BUXBAUM-.in. BUXBAUM-A-.in. buxBAUM-ALEX-.in.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:39
L4	38645	(mask photomask photo-mask reticle) near2 (substrate blank)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:40
L5	3	((mask photomask photo-mask reticle) near2 (substrate blank)) with ((increas$3 improv$6) with ((shelf near2 life) stability)) with (resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation)))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:42
L6	65	((increas$3 improv$6) with ((shelf near2 life) stability)) with (resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) with bak$3	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:43
L8	14065	(soft adj bak$3) (post adj application adj bak$3) pab! pre-bak$3 prebak$3	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:41
L9	5304	430/5,327,330.ccls 427/372.2,385.5.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:41

L10	18	((mask photomask photo-mask reticle) near2 (substrate blank)) with (resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) with ((soft adj bak$3) (post adj application adj bak$3) pab! pre-bak$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:44
L11	20	((mask photomask photo-mask reticle) near2 (blank)) same (resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) same ((soft adj bak$3) (post adj application adj bak$3) pab! pre-bak$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:44
L12	4	((mask photomask photo-mask reticle) near2 (substrate blank)) same (resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) same ((soft adj bak$3) (post adj application adj bak$3) pab! pre-bak$3) same (stable stability shelf adj life)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:45
L13	74	(((mask photomask photo-mask reticle) near (substrate blank))) with (shelf near life time near lapse stor$4 stable stability time near lag shipping shipped ship) with (((soft adj bak$3) (post adj (application apply$3 appli$4) adj bak$3) pab! pre-bak$3) (resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))) coated bak$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:47
L14	787958	resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:47
L15	4705	chemical$3 adj2 amplif$4	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:48
L16	4470	14 with 15	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:48
L17	41	14 with 15 with 4	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:49
L18	6	8 same 17	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:49

L19	85	8 and 9	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:51
L20	58	8 and 9 and 14	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:55
L21	6530	4 near5 14	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:55
L22	85	4 with 14 with 8	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:57
L23	3	4 with 14 with 8 with (shelf adj life storage store stored storing stable stability)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 18:06
L24	6	4 same 14 same 8 same (shelf adj life storage store stored storing stable stability)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 17:57
L25	334	16 with (shelf adj life storage store stored storing stable stability)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 18:10
L26	8	25 same blank	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 18:08
L27	5	25 same 8	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 18:09
L28	10	16 same (shelf adj life storage store stored storing stable stability) same 8	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 18:12
L29	321	14 same (shelf adj life storage store stored storing stable stability) same 8	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 18:17
L30	27	29 and 430/5.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 18:14

L31	100	14 same (shelf adj life storage store stored storing stable stability) same 8 same (mask photo-mask photomask blank)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 18:18
L32	95	31 not 30	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 18:22
L33	335	14 with 8 with (improv$6 better increas$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 18:39
L34	150	(photomask photo-mask) with coat$3 with blank	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 18:23
L35	64	(photomask photo-mask) with coat$3 with blank	USPAT	OR	ON	2005/02/23 18:24
L36	40	(photomask photo-mask) with coat$3 with blank with 14	USPAT	OR	ON	2005/02/23 18:27
L37	13	(photomask photo-mask) with coat$3 with blank with 14 with substrate	USPAT	OR	ON	2005/02/23 18:27
L38	0	14 with 8 with (improv$6 better increas$3) with blank	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 18:31
L39	55	14 near3 8 near3 (improv$6 better increas$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 18:31
L40	9	33 same 15	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 18:39
L41	35	33 with (known conventional$3 typical$3 prefer$6)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/02/23 18:40